

L Number	Hits	Search Text	DB	Time stamp
1	299119	mask or photomask or reticle	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:09
2	88978	multilayer	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:09
3	467370	reflection or reflective or reflect	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:09
4	94779	absorber	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:09
5	15270	(mask or photomask or reticle) and multilayer	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:09
6	5668	multilayer same (reflection or reflective or reflect)	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:09
7	784	absorber and ((mask or photomask or reticle) and multilayer)	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:09
8	51665	tantalum	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:10
9	110	(absorber and ((mask or photomask or reticle) and multilayer)) and tantalum	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:10
10	362	(tantalum or ta) same absorber	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:10
11	27	((absorber and ((mask or photomask or reticle) and multilayer)) and tantalum)	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:14
12	2120	and ((tantalum or ta) same absorber) (chromium or cr) same multilayer	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:46
13	5	((((absorber and ((mask or photomask or reticle) and multilayer)) and tantalum) and ((tantalum or ta) same absorber)) and ((chromium or cr) same multilayer)	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:16
14	2115	((chromium or cr) same multilayer) not (((absorber and ((mask or photomask or reticle) and multilayer)) and tantalum) and ((tantalum or ta) same absorber)) and ((chromium or cr) same multilayer))	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:16
15	5	((chromium or cr) same multilayer) not (((chromium or cr) same multilayer) not (((absorber and ((mask or photomask or reticle) and multilayer)) and tantalum) and ((tantalum or ta) same absorber)) and ((chromium or cr) same multilayer)))	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:23
16	19	((absorber and ((mask or photomask or reticle) and multilayer)) and tantalum) and ((chromium or cr) same multilayer)	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:23
17	5510	(chromium or cr) same (reflection or reflective or reflect)	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:47
18	58	(absorber and ((mask or photomask or reticle) and multilayer)) and ((chromium or cr) same (reflection or reflective or reflect))	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:47
19	26	tantalum and ((absorber and ((mask or photomask or reticle) and multilayer)) and ((chromium or cr) same (reflection or reflective or reflect)))	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:50
20	5452	((chromium or cr) same (reflection or reflective or reflect)) not ((absorber and ((mask or photomask or reticle) and multilayer)) and ((chromium or cr) same (reflection or reflective or reflect)))	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:50

21	58	((chromium or cr) same (reflection or reflective or reflect)) not ((chromium or cr) same (reflection or reflective or reflect)) not ((absorber and (mask or photomask or reticle) and multilayer)) and ((chromium or cr) same (reflection or reflective or reflect)))	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:50
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